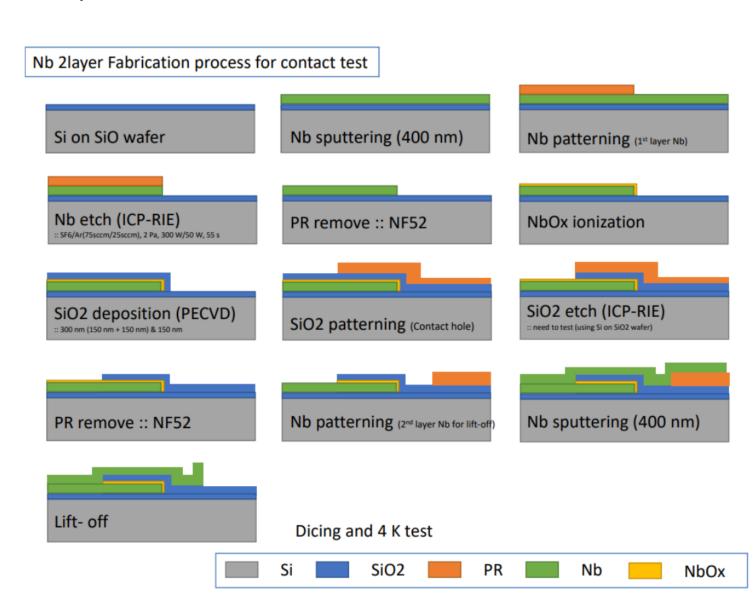
Weekly meeting

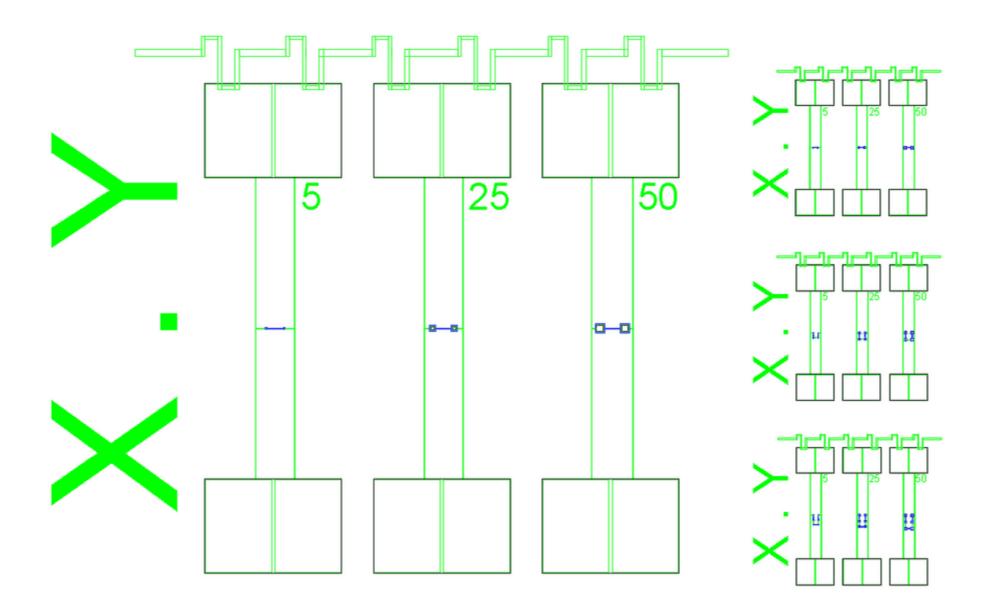
2019/11/15

Working status

- 1. Fabrication project: 2nd niobium deposition onto the 1st niobium layer (with Dr. Jeon, Freerik)
- We are using two wafers differing in width of SiO2 layer
- SiO2 pattering is over (11/14)
- Second Nb pattering is scheduled at 11/19 in KRISS







		DE	aga	tototo	mmm	mmm	офо	Total Control			
		ä	-	~ _	2	23		6			
		~	000 000		2		000 000				
		2000	9000		2	E 000		**************************************			
	2000	2000	9 000	_ 	B B	- 444		2000	9000		
	~		2,000 6,000		27.12	2,13	2,14 4,000	27.15	2.16		
- ·			2000			, COCSC)	4000 6 0000		= 000		-
		= 000	0000 12 12 12 12 12 13 13 14 14 15 16 16 16 16 16 16 16 16 16 16 16 16 16		2 III	2000	9 mmm 9 mmm	2000	©		
	~000	~	2,000					2200	2000	J	
			2 mmm	273		2.25	4 000 121 000			7	
		2 dd d	8 111	2 HOW	2000	4 mm	2.2 0.000	2111	7		
		8			8224 0000	6.25 000000000000000000000000000000000000					